

| Application/Control No. | Applicant(s)/Patent under Reexamination | Applicant(s)/Patent under Reexamination | |
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| 10/617,374 | CHOU, CHAO-MU | | |
| Examiner | Art Unit | | |
| Jack W. Lavinder | 3677 | | |

| SEARCHED | | | | |
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| Class | Subclass | Date | Examiner | |
| 24 | 399,400,4 59,487, 517-520 | 6/3/2006 | JWL | |
| | 570,571 | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | |
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